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JUL 02 2004

**OFFICIAL****Patent**Customer No.: 31561  
Docket No. 11437-US-PA  
Application No.: 10/604,835**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Applicant : Liu et al.  
Application No. : 10/604,835  
Filed : 2003/08/21  
For : METAL SILICIDE STRUCTURE AND METHOD OF  
FORMING THE SAME  
Art Unit : 2811  
Examiner : VU, QUANG D

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**TRANSMITTAL LETTER**

002-1-703-872-9306

(Via fax: 3 pages, followed by confirmation copy via courier)

Assistant Commissioner for Patents  
Arlington, Virginia 22202

Dear Sirs,

In response to the Office Action dated June 15, 2004, please find the relevant paper in response to paper No. 060204. Following the fax transmission, a hard copy via courier will also be forwarded to the Office.

Enclosed documents via courier will include:

- ☒ Response to Restriction Requirement in (1) pages
- ☒ Fax confirmation report
- ☒ Prepaid return postcard

I believe that no fee is incurred. However, the Commissioner is authorized to charge any fees required in connection with the filing of this paper to account No. 50-2620 (Order No.: 11437-US-PA)

Thank you for your assistance in the subject matter. If you have any questions, please feel free to contact me.

Patent

Customer No.: 31561  
Docket No. 11437-US-PA  
Application No.: 10/604,835

Respectfully Submitted,  
JIANQ CHYUN Intellectual Property Office

Date: July 2, 2004

By: Belinda Lee  
Belinda Lee  
Registration No.: 46,863

Please send future correspondence to:

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**RESPONSE TO RESTRICTION REQUIREMENT**

ASSISTANT COMMISSIONER FOR PATENTS

Arlington, VA 22202

Dear Sirs,

In response to the Office Action, mailed on June 15, 2004, Applicant would like to elect Group I, claims 1-10, drawn to a method for forming a metal silicide layer, classified in class 438, subclass 682. Please cancel Group II, claims 11-14, drawn to a metal silicide structure, classified in class 257, subclass 388 without waiver, prejudice or disclaimer.

Thank you for your assistance in the subject matter. If you have any questions, please feel free to contact me.

Respectfully Submitted,  
JIANQ CHYUN IP Office

Date:

*July 2, 2004*

By:

*Belinda Lee*

Belinda Lee

Registration No.: 46,863

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